Effect of ambient on the thermal parameters of a micromachined bolometer

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The thermal characterization of bolometers is needed for optimal design as well as applications. In this letter, we present results of the effect of environment on the thermal properties of micromachined bolometers. We find that while in vacuum, the thermal response can be represented by a single time constant, in presence of an ambient gas, the thermal response can no longer be described by a single time constant. This will have a direct implication on frequency dependence of responsivity. We present a model to explain our data which involves the finite diffusion time in the ambient gas and the associated extra thermal mass.

Microbolometer arrays fabricated using the Microelectromechanical systems technique¹ are used for thermal image processing. Thermal response characterization of microbolometers is needed for optimal design. Generally, thermal characteristics are quantified through two measurable quantities: the thermal resistance of the bolometer to the substrate R_{th} and the thermal relaxation time τ . The thermal parameters are measured at a single bias voltage across the bolometer and also as a function of applied bias across the bolometer.^{2,3} Application of excess bias leads to heating of the bolometer. This provides thermal characteristics at elevated temperatures. In this letter, we address the specific issue of ambient. The ambient gas provides an additional thermal link of the bolometer to the substrate in addition to the support hinge and reduces R_{th} . This changes the responsivity of the bolometer, which is $\propto R_{th}$. By measuring the thermal characteristics in vacuum, air, and helium gas ambient, we have shown that the ambient not only changes the thermal link resistance R_{th} , but more importantly, changes the nature of the time-temperature ($t-T$) response curve. In vacuum, the $t-T$ curve, on application of a step heat input, shows exponential growth with one time constant, while in air and in He, it shows a significant departure from such a simple behavior. We modeled the performance of the bolometer and have found that the departure from a single time constant arises because a finite mass of the gas ambient becomes associated with the thermal response of the bolometer, giving rise to an extra heat capacity and an associated thermal relaxation time. This changes the frequency response of the bolometer in presence of a *cw* sinusoidal signal input.

The bolometer used in this investigation consists of an array of 4×4 elements, each of which is a Si_3N_4 membrane ($50 \mu\text{m} \times 50 \mu\text{m}$) grown on a Si wafer. A scanning electron microscope (SEM) image of a single element is shown in Fig. 1. The elements are connected to the main Si frame by Si_3N_4 hinges ($5\text{-}\mu\text{m}$ width $\times$ $2\text{-}\mu\text{m}$ length $\times$ $1\text{-}\mu\text{m}$ thickness). The thermal element is a Ti heater film $700\text{-}\text{\AA}$ thick and $4\text{-}\mu\text{m}$ wide.

The experiments were carried out in a chamber that can be pumped down to a vacuum of 10^{-5} Torr. It can be filled with any desired gas up to a pressure of 1 atm. The thermal characteristics were measured by giving a step power input to the bolometer thermal element (Ti) and recording the temperature response of the bolometer as a function of time, which we call the ($t-T$) curve. For this we used the Ti element both as a heater and thermometer. To use the Ti element as the thermometer, we calibrated the resistance of the Ti as a function of temperature using a standard platinum thermometer in the temperature range 100 to 350 K. The temperature coefficient of resistance (TCR) $= 1/R(dR/dT) \sim 4 \times 10^{-3}/\text{K}$. The observed calibration is shown in the inset of Fig. 1. The $t-T$ curve was obtained by recording the voltage across the Ti element (which has a constant current bias) using a 16-bit A/D card at a rate of 10-K points/s. Step power input of amplitude P_{in} leads to a rise in temperature ΔT . In the steady state, $\Delta T = P_{in} R_{th}$. To analyze whether the $t-T$ curve is governed by one time constant or not, we have plotted the quantity $\ln\{1 - [T(t) - T_0]/\Delta T\}$ versus t , where T_0 is the temperature of the bolometer in the absence of the power input and is equal to the substrate temperature. When the $t-T$ curve has a single time constant (τ) the $\ln\{1 - [T(t) - T_0]/\Delta T\}$ versus t curve is a straight line whose inverse slope gives τ . Any departure from the single τ behavior will make this curve deviate from a straight line.

FIG. 1. SEM image of a single bolometer element. The inset shows the temperature dependence of the resistance of the Ti element.

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FIG. 2. Thermal response curve of the microbolometers in vacuum, air, and He gas. Lines show fits from the model. Note the single relaxation time behavior in vacuum and two time constants dominated behavior in an ambient gas.

Typical examples of observed $\ln\{1 - [T(t) - T_0]/\Delta T\}$ versus t curves are shown in Fig. 2 for vacuum and with air and helium ambients. In vacuum, the thermal response can be characterized by a single τ , while in air and in He, the curve can be described by a combination of two time constants. From the given P_{in} and the observed temperature rise ΔT , we could obtain R_{th} for all the experimental conditions: vacuum, air, and He ambients. The observed R_{th} is shown in Fig. 3 as function of temperature. In vacuum (pressure $< 10^{-3}$ mbar) $R_{th} \approx 2.5 \times 10^4$ K/W at 300 K and has a shallow temperature dependence. In vacuum, in absence of other thermal pathways, R_{th} will be determined by conduction through the hinges and the radiation contribution. Absence of a T^{-3} -type of a steep temperature dependence in R_{th} shows that radiation makes a negligible contribution and R_{th} will be determined by the thermal conductivity Λ of the hinge material. From the hinge dimension and the observed R_{th} , we calculate $\Lambda \sim 30$ W/mK, which is the same as the bulk value. In air and in He, there is a large reduction in R_{th} because the air and He ambients provide additional thermal links. Understandably, He, which has higher thermal conductivity, shows a lower R_{th} . Thus, in gas environment, it is the gas that determines the value of R_{th} .

Next, we analyze the observed thermal response curve shown in Fig. 2 using a simple model. The basic physics of the model is that the presence of an ambient gas not only provides a thermal link (thus changing R_{th}), but also pro-

FIG. 3. The thermal resistance R_{th} in vacuum, air, and He gas as measured from the steady temperature rise ΔT and P_{in} . The inset shows the heat capacity of the membrane as determined from our experiment.

FIG. 4. A thermal model of the bolometer in presence of an ambient.

vides a thermal mass, the heat diffusion through which has a finite time that will lead to additional time constants to the thermal response of the bolometer. The model is outlined subsequently (see Fig. 4). To simplify, we have used the approach of a “lumped circuit” model, in which the thermal masses are represented as capacitors and the thermal resistances are shown as electrical resistors. This is less rigorous than the actual solution of the heat diffusion equation, but it is simple to solve and it captures the essential physics. In Fig. 4, $T_m [= T(t) - T_0]$ is the temperature of the membrane with respect to bath (substrate) temperature T_0 . T_a is the average temperature of air with respect to the bath. R_1 is the thermal resistance of the hinge and C_1 is the heat capacity of the membrane and hinge combination. C_2 is the heat capacity of ambient gas that couples to the bolometer and R_2 is the thermal link due to the gas. We have taken the thermal links of gas to membrane and gas to substrate both as R_2 for simplicity without sacrificing any feature. The heat balance equations are

$$P_{in}(t) = \frac{T_m - T_a}{R_2} + C_1 \frac{dT_m}{dt} + \frac{T_m}{R_1}, \quad (1)$$

$$\frac{T_m - T_a}{R_2} = \frac{T_a}{R_2} + C_2 \frac{dT_a}{dt}. \quad (2)$$

For a step heating, $P_{in}(t) = 0$ for $t < 0$, and $= P_{in}$ for $t \geq 0$. The solution to this set of coupled differential equations gives

$$T_m = P_{in} \{ 1 - \exp(-gt) [P_2 \exp(-ft) + P_3 \exp(ft)] \}, \quad (3)$$

where

$$2g = [(c^{-1} + 2)/\tau_2] + 1/\tau_1,$$

$$4f^2 = (1/c^2 \tau_2^2) + (2/c \tau_1 \tau_2) + (1/\tau_1 - 2/\tau_2)^2,$$

$$P_1 = 2P_{in} / [C_1 \tau_2 (g^2 - f^2)],$$

$$P_2 = [1/(2f)] [\tau_2 (g^2 - f^2)/2 - (g - f)],$$

$$P_3 = [1/(2f)] [(g + f) - \tau_2 (g^2 - f^2)/2].$$

Here, we have defined $\tau_1 = R_1 C_1$, $\tau_2 = R_2 C_2$, and $c = C_1/C_2$. The model gives two time constants: $(g - f)^{-1}$ and $(g + f)^{-1}$. In vacuum, the thermal resistance $R_2 \rightarrow \infty$, $R_{th} = R_1$, and the thermal response is controlled by one time constant τ_1 . The fits to the data obtained using this model are shown in Fig. 2 as solid lines. In the case of the gas ambient, the response curve with two time constants (Eq. 3) fits the observed data very nicely over the complete range of t over which data are taken. Typical τ_1 at $T = 300$ K is ≈ 0.5

TABLE I. Thermal parameters obtained from fits to the experimental data.

Ambient	τ_1 (ms)	R_1 (K/W)	C_1 (nJ/K)	τ_2 (ms)	R_2 (K/W)	C_2 (nJ/K)
Vacuum	0.53	2.5×10^4	20	∞	∞	...
Air	0.53	2.5×10^4	20	0.37	4.0×10^3	155
Helium	0.53	2.5×10^4	20	0.40	3.1×10^3	222

ms. From the observed value of R_1 (obtained from the steady-state value of ΔT and known value of P_{in}), we could find the heat capacity C_1 of the bolometer as a function of T for the temperature range studied (Fig. 3 inset). C_1 has the main contribution from the bulk of the heat capacity of the bolometer and approximately 1/3 the heat capacity of the hinges. Using this, we obtain a specific heat of ≈ 1.95 J/g K for the material of the bolometer and the hinge. This is much larger than the value of specific heat of ≈ 1 J/g K for Si_3N_4 . A value of ~ 1.5 J/g K for the specific heat of Si_3N_4 has also been reported.⁴

At steady state, $t \rightarrow \infty$, and $T_m = \Delta T = P_1$. From the observed fits of the data to Eq. (3), the time constants g^{-1} , f^{-1} , and constants P_2 and P_3 can be found. Using the values of τ_1 , R_1 , and C_1 as observed in the case of the vacuum, we can find out τ_2 , R_2 , and C_2 , the parameters for the gas ambient. (In our model, the parameters τ_1 , R_1 , and C_1 depend only on the membrane and hinge material, and are independent of the ambient gas). The parameters τ_2 , R_2 , and C_2 are given in Table I.

The heat capacity C_2 is due to the extra thermal mass of gas around the bolometer through which the heat diffuses over the time scale of one to few τ_2 . The volume of the gas calculated from the heat capacity is $\sim 1.34 \times 10^{-10}$ m³ for air and $\sim 2.34 \times 10^{-10}$ m³ for He. If the volume in which the

heat diffuses is taken to be a hemisphere (since the cavity below the membrane ~ 2 μm), its radius (r_g) ≈ 400 μm for air and 480 μm for He. r_g thus should be comparable to the thermal diffusion length L_D of the gas. The L_D is estimated from the relation $L_D \approx \pi(\tau_2 D)^{0.5}$, where D is the diffusivity of the gas. From the standard $D = 5 \times 10^{-5}$ m² s⁻¹ for air and $D = 1.1 \times 10^{-4}$ m² s⁻¹ for He, we obtain $L_D \approx 440$ μm for air and ≈ 650 μm for He. It can be seen for both the gases, $r_g \sim L_D$. This is a good validation of the essential physics used in the simple model. In a previous report, it was shown that the R_{th} increases as the ambient is pumped and the vacuum is reached.⁴ However, the issue of two relaxation times has not been addressed. It may be appreciated that the deviation from a single relaxation time (τ) dominated thermal response as observed in a gas ambient will severely change the often used expression for the responsivity, $R(\omega) \propto (R_{\text{th}} / \sqrt{1 + \omega^2 \tau^2})$ which is strictly valid when the bolometer thermal response can be characterized by a single τ .

To summarize, in this letter, we studied the effect of ambient gas on the thermal response of a microbolometer. We find that, while in vacuum, the thermal response can be characterized by a single time constant, the presence of ambient gas changes the nature of the thermal response and it needs two time constants to describe it. With a simple model, we could connect the observed behavior to the physical parameters of the ambient gas.

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